

1011 U.S. PTO
10/042666
01/08/02

BEST AVAILABLE COPY

PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10042666	FILING DATE 01/08/2002	CLASS 427 448	SUBCLASS 523	GAU 1715 1734	EXAMINER Rad. R. F. LAVILLA
----------------------	---------------------------	---------------------	-----------------	---------------------	--------------------------------

**APPLICANTS: Han Nianci; Xu Li; Shih Hong;

**CONTINUING DATA VERIFIED:

** FOREIGN APPLICATIONS VERIFIED:

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO
35 USC 119 condition's met <input type="checkbox"/> yes <input type="checkbox"/> no		003330 USA/ETCH/METAL/JB
Verified and Acknowledged Examiners's initials		
TITLE : Process chamber having component with yttrium-aluminum coating		

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G
Assistant Examiner		DRAWING	
ISSUE FEE		Sheets Drwg.	Figs. Drwg.
Amount Due	Date Paid	Print Fig.	
Primary Examiner		Application Examiner	
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	
WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.			

FILED WITH:

☐ DISK (CRF)

☐ CD-ROM

(Attached in pocket on right inside flap)